

# INTERNATIONAL SEARCH REPORT

International application No.  
PCT/CN2004/001384

## A. CLASSIFICATION OF SUBJECT MATTER

IPC7 C08J 3/00

According to International Patent Classification (IPC) or to both national classification and IPC

## B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC C08J 3/, 5/, 7/

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

WPI, PAJ, EPODOC, CNPAT, CNKI, contact angle, polymer, wetting, wettability, surface, substrate, matrix, burnish, polish, rub, sanding

## C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	"Surface Modification of PTFE by CH <sub>4</sub> /O <sub>2</sub> Plasma", ChenXiaoDong et al, Journal of Radiation Research and Radiation Process. No.1, 2000, Feb, 2000	1
A	CN 1192224 A (COMMONWEALTH SCI & RES ORG, 02.09.1998)	1
A	US 6409581 (MICRO TECHNOLOGY INC, 25.06.2002)	1
A	JP 5-039374 A (DAINIPPON PRINTING CO LTD, 19.02.1993)	1
A	JP 4-353529 A (TEIJIN LTD, 08.12.1992)	1

☐ Further documents are listed in the continuation of Box C. ☒ See patent family annex.

* Special categories of cited documents:	"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
"A" document defining the general state of the art which is not considered to be of particular relevance	"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone
"E" earlier application or patent but published on or after the international filing date	"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art
"L" document which may throw doubts on priority claim (S) or which is cited to establish the publication date of another citation or other special reason (as specified)	"&" document member of the same patent family
"O" document referring to an oral disclosure, use, exhibition or other means	
"P" document published prior to the international filing date but later than the priority date claimed	

Date of the actual completion of the international search  
05.Jan.2005 (05.01.2005)

Date of mailing of the international search report

17 - FEB 2005 (17 - 02 - 2005)

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**INTERNATIONAL SEARCH REPORT**  
Information on patent family members

International application No.  
PCT/CN2004/001384

CN 1192224 A	02.09.1998	ES 2213776 T T3	01.09.2004
		WO 9702310 A1	23.01.1997
		AU 6183096 A	05.02.1997
		EP 835279 A1	15.04.1998
		CZ 9704159 A3	15.04.1998
		AU 695160 B	06.08.1998
		BR 9609594 A	23.02.1999
		NZ 310926 A	25.02.1999
		US 5922161 A	13.07.1999
		MX 9800167 A1	01.03.1998
		TW 397853 A	11.07.2000
		RU 2163246 C2	20.02.2001
		MX 204940 B	25.10.2001
		EP 835279 B	17.12.2003
		DE 69631136E E	29.01.2004
US 6409581	25.06.2002	NONE	
JP 5-039374 A	19.02.1993	NONE	
JP 4-353529 A	08.12.1992	NONE	

# 国际检索报告

国际申请号  
PCT/CN2004/001384

## A. 主题的分类

IPC7 C08J 3/00

按照国际专利分类表(IPC)或者同时按照国家分类和 IPC 两种分类

## B. 检索领域

检索的最低限度文献(标明分类系统和分类号)

IPC C08J 3/, 5/, 7/

包含在检索领域中的除最低限度文献以外的检索文献

在国际检索时查阅的电子数据库(数据库的名称, 和使用的检索词(如使用))

WPI,PAJ,EPODOC, CNPAT, CNKI, contact angle, polymer, wetting, wettability, surface, substrate, matrix, burnish, polish, rub, sanding

## C. 相关文件

类 型*	引用文件, 必要时, 指明相关段落	相关的权利要求
A	“聚四氟乙烯的 CH <sub>4</sub> /O <sub>2</sub> 混合气体等离子体表面亲水改性研究”, 陈晓东等, 《辐射研究与辐射工艺学报》, 2000 年第 1 期, 2000 年 2 月	1
A	CN 1192224 A (联邦科学及工业研究组织, 1998.2.19)	1
A	US 6409581 (MICRO TECHNOLOGY INC, 2002.6.25)	1
A	JP 5-039374 A (DAINIPPON PRINTING CO LTD, 1993.2.19)	1
A	JP 4-353529 A (TEIJIN LTD, 1992.12.8)	1

☐ 其余文件在 C 栏的续页中列出。

☒ 见同族专利附件。

\* 引用文件的具体类型:

“A” 认为不特别相关的表示了现有技术一般状态的文件

“E” 在国际申请日的当天或之后公布的在先申请或专利

“L” 可能对优先权要求构成怀疑的文件, 为确定另一篇引用文件的公布日而引用的或者因其他特殊理由而引用的文件

“O” 涉及口头公开、使用、展览或其他方式公开的文件

“P” 公布日先于国际申请日但迟于所要求的优先权日的文件

“T” 在申请日或优先权日之后公布, 与申请不相抵触, 但为了理解发明之理论或原理的在后文件

“X” 特别相关的文件, 单独考虑该文件, 认定要求保护的发明不是新颖的或不具有创造性

“Y” 特别相关的文件, 当该文件与另一篇或者多篇该类文件结合并且这种结合对于本领域技术人员为显而易见时, 要求保护的发明不具有创造性

“&” 同族专利的文件

国际检索实际完成的日期

05.1 月 2005 (05.01.2005)

国际检索报告邮寄日期

17. 2 月 2005 (17. 02. 2005)

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国际检索报告  
关于同族专利的信息

国际申请号  
PCT/CN2004/001384

检索报告中引用的 专利文件	公布日期	同族专利	公布日期
CN 1192224 A	02.09.1998	ES 2213776 T T3	01.09.2004
		WO 9702310 A1	23.01.1997
		AU 6183096 A	05.02.1997
		EP 835279 A1	15.04.1998
		CZ 9704159 A3	15.04.1998
		AU 695160 B	06.08.1998
		BR 9609594 A	23.02.1999
		NZ 310926 A	25.02.1999
		US 5922161 A	13.07.1999
		MX 9800167 A1	01.03.1998
		TW 397853 A	11.07.2000
		RU 2163246 C2	20.02.2001
		MX 204940 B	25.10.2001
		EP 835279 B	17.12.2003
		DE 69631136E E	29.01.2004
US 6409581	25.06.2002	NONE	
JP 5-039374 A	19.02.1993	NONE	
JP 4-353529 A	08.12.1992	NONE	